

**PATENT APPLICATION**

Serial No: 10/\_\_\_\_\_  
Filing Date: December 12, 2003  
First Named Inventor: Steven A. Soper  
Title: Photoresist-Free Micropatterning on Polymer Surfaces  
Atty Docket: 0023.1 Soper

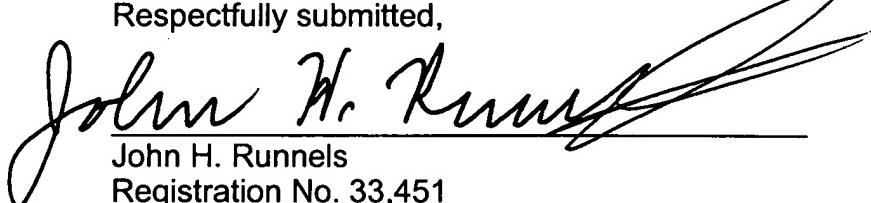
MS PATENT APPLICATION  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**INFORMATION DISCLOSURE STATEMENT**

In accordance with the duty of candor and good faith imposed by 37 C.F.R. §1.56 and means of complying therewith according to 37 C.F.R. §§1.97 and 1.98, the references listed on the attached Information Disclosure Citation are called to the attention of the United States Patent and Trademark Office in connection with the above-identified patent application. A copy of the cited references are enclosed herewith. No admission is made that the cited art represents the prior art or that the cited art is the most material art.

The Office is urged to consider the cited references and to make an independent decision with respect to their materiality.

Respectfully submitted,

  
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<b>Substitute for form 1449A/PTO</b>	<b>U.S. Patent and Trademark Office U.S. Department of Commerce</b>					<b>COMPLETE IF KNOWN</b>	
<b>INFORMATION DISCLOSURE CITATION</b> (use as many sheets as necessary)					<b>Application Number</b>	10/_____	
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					<b>First Named Inventor</b>	Steven A. Soper	
					<b>Art Unit</b>		
					<b>Examiner Name</b>		
Sheet	1	of	2		<b>Attorney Docket No.</b>	0023.1 Soper	

<b>U.S. PATENT DOCUMENTS</b>						
Exam. Initial	Document No.	Date	Name	Class	Subcl.	File Date
	6,436,615	8/02	Brandow et al.	430	324	6/25/99
	5,051,312	9/91	Allmer	428	458	

**Note:** Copies of U.S. Patents are not enclosed. See OG Notice of August 5, 2003.

<b>FOREIGN PATENT DOCUMENTS</b>				
Exam. Initial	Foreign Patent Document	Publication Date MM-DD-YY	Name of Patentee or Applicant of Cited Document	Translation ?
	Country Code / Number / Kind			
	WO 02/18288	03-07-02	Hevesi et al.	
	WO 00/56808	09-28-00	Larsson et al.	

<b>OTHER DOCUMENTS</b> (Including Author, Title, Date, Pertinent Pages, etc.)	
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	A. Henry et al., "Selective deposition of metals on plastics used in the construction of microanalytical devices: Photo-directed formation of metal features on PMMA," <i>J. Phys. Chem. B</i> , vol. 105, pp. 8755-8761 (2001)
	A. Henry et al., "Surface modification of poly(methyl methacrylate) used in the fabrication of microanalytical devices," <i>Anal. Chem.</i> , vol. 72, pp. 5331-5337 (2000)
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<b>EXAMINER SIGNATURE</b>	<b>DATE CONSIDERED</b>
<p>* EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw a line through the citation if not in conformance and not considered. Include copy of this form with next communication to applicant.</p>	

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OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)					
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